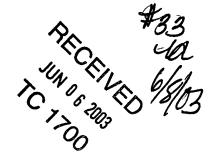


## PATENT



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT:

HENNHÖFER ET AL.

SERIAL NO.:

09/032,305

EXAMINER: R. KUNEMUND

FILED:

FEBRUARY 27, 1998

GROUP: 1765

TITLE:

PROCESS FOR TREATING A POLISHED SEMICONDUCTOR WAFER IMMEDIATELY AFTER THE SEMICONDUCTOR WAFER

HAS BEEN POLISHED

## RESPONSE TO FINAL OFFICE ACTION

MAIL STOP AFTER FINAL Commissioner for Patents P.O.BOX 1450 Alexandria, VA 22313-1450

Dear Sir:

This is in response to the Final Office Action dated December 4, 2002, with the time for reply having been extended for three months, from MARCH 4, 2003, until JUNE 4, 2003, and with a Notice of Appeal and the Appeal Fee having been filed and paid.

The Remarks begin on Page 2 of this document.